Electronic Filing System (EFS) Data Electronic Patent Application Submission USPTO Use Only

EFS ID:

63514

Application ID:

10710244

STRUCTURES AND METHODS FOR

MANUFACTURING P-TYPE

MOSFET WITHGRADED

Title of Invention:

EMBEDDED SILICON-GERMANIUM

SOURCE-DRAIN AND/OR

EXTENSION

First Named Inventor:

Huilong Zhu

Domestic/Foreign Application:

Domestic Application

Filing Date:

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Submission Type:

Utility Patent Filing

Filing Type:

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PATENT	APPLICATION	SERIAL	NO.	

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